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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/665,568		09/22/2003	Kenji Hori	111608.01	6155	
25944	7590	03/22/2005		EXAM	EXAMINER	
OLIFF & B		E, PLC	HASAN, MOHAMMED A			
P.O. BOX 19928 ALEXANDRIA, VA 22320				ART UNIT	PAPER NUMBER	
				2873	***	
				DATE MAILED: 03/22/2005	DATE MAILED: 03/22/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
	10/665,568	HORI, KENJI					
Office Action Summary	Examiner	Art Unit					
	Mohammed Hasan	2873					
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address					
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).					
Status							
1)⊠ Responsive to communication(s) filed on 24 Ja	anuary 2005.						
2a) This action is FINAL . 2b) This							
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4) ☐ Claim(s) 5,6,8 and 9 is/are pending in the application 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 5,6,8 and 9 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	vn from consideration.						
Application Papers							
9) The specification is objected to by the Examine							
10) ☐ The drawing(s) filed on 22 September 2003 is/a							
Applicant may not request that any objection to the							
Replacement drawing sheet(s) including the correcting 11) The oath or declaration is objected to by the Ex		• •					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of	s have been received. s have been received in Application ity documents have been receive (PCT Rule 17.2(a)).	on No d in this National Stage					
Attachment(s)							
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary (Paper No(s)/Mail Dat 5) Notice of Informal Pa 6) Other:						

Art Unit: 2873

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 5 and 8 are rejected under 35 U.S.C. 102 (e) as being anticipated by Kouchiyama et al (US 2002/0030898 A1).

Regarding claim 5, Kouchiyama et al discloses (refer to figures 1 - 8) a method of adjusting the optical thickness of a lens (1) made from a material transparent to light to be used comprising: etching a surface of the lens to reduce the optical thickness (dry etching, i.e., reduce the optical thickness) and manufacturing the lens before etching the surface of the lens to reduce the optical thickness (paragraph 0050 – 0062, paragraph 0019).

Regarding claim 8, Kouchiyama et al discloses, an optical thickness has been adjusted by a method (i.e., the process shown in figures 18 - 21).

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Claim Rejections - 35 USC § 103

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 6 and 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kouchiyama et al (US 2002/0030898 A1).

Regarding claim 6 as applied to claim 5, Kouchiyama et al discloses (refer to figures 1 – 8) a method of adjusting the optical thickness of a lens (1), an etching a surface of the lens (1) to reduce an optical thickness (dry etching, i.e., reduce the optical thickness) and manufacturing the lens before etching the surface of the lens (paragraph 0050 – 0062, paragraph 0019). Kouchiyama et al discloses all of the claim limitations except etching is performed to bring an optical thickness of the manufactured lens to a target optical thickness of the lens. However, Kouchiyama et al discloses (refer to figures 1-8) manufacturing lens and a lens forming step by dry etching (refer to figure 5). Kouchiyama et al further discloses manufacturing lens (i.e., aberration allowable range 0.4 rms) (paragraph 0011).

It would have been obvious to one of ordinary skill in the art at the time invention was made to provide an optical thickness of the manufactured lens to target optical thickness when etching is performed for the purpose of an optical device have a small

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size and a large radius of curvature to a high accuracy as taught by Kouchiyama et al (paragraph 0016).

Regarding claim 9, Kouchiyama et al discloses (refer to figures 1 – 8) a lens (1) whose optical thickness has been adjusted by method (paragraph 0050 – 0062, paragraph 0019).

3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The closest prior art

Sudoh (6,563,652 B2) discloses, a lens barrel and projection aligner.

Ebina et al (US 2004/0004770 A1) discloses, a micro-lens sheet and projection screen.

Conclusion

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mohammed Hasan whose telephone number is (571) 272-2331. The examiner can normally be reached on M-TH, 7:00 AM to 5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Epps can be reached on (571) 272- 2328. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

MH March 15, 2005

> Georgia Epps Supervisory Patent Examiner Technology Center 2800